

<b>Notice of References Cited</b>		Application/Control No.	Applicant(s)/Patent Under Reexamination MAKIMOTO ET AL.	
		Examiner Tram H. Nguyen	Art Unit 2818	Page 1 of 1

**U.S. PATENT DOCUMENTS**

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
*	A	US-2002/0195619	12-2002	Makimoto et al.	257/197
	B	US-			
	C	US-			
	D	US-			
	E	US-			
	F	US-			
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	H	US-			
	I	US-			
	J	US-			
	K	US-			
	L	US-			
	M	US-			

**FOREIGN PATENT DOCUMENTS**

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	N					
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**NON-PATENT DOCUMENTS**

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	K. Kumakura, T. Makimoto and N. Kobayashi, Low-Resistance Nonalloyed Ohmic Contact to p-type GaN Using Strained InGaN Contact Layer, Applied Physics Letters, Vol. 79, No. 16, pp 2588-2590 (2001).
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